

INDEX

Accommodation coefficient. Collision of gas atom and solid, calculated values, less than measured classical theory of, 2 values, 2 quantum theory of, 5 definition, 1, 2 Contact potential, effect of surface impurities, 4, 60, difference between bare and hydrogen covered tungsten, 30, 58 94, 95-7, 99, 102-3 mass of gas and solid atoms, deformation of hydrogen films on tungsten, 57 pendence on, 2 measurement, experimental arrangein study of monolayers, experiment, 10 mental procedure, 57 of helium, measured values, 4 sodium films on tungsten, 57 temperature variation of, 4-5 to measure evaporation of oxygen from tungsten, 77 of neon, measured values, 6, 60-1, variation with fraction of surface sensitive to adsorbed films, 6-7, covered, 58 11, 60, 95-9, 102-3 Crystal planes, temperature variation of, 61 aged tungsten, important plane for, of rotational energy, 7 16 relation to kinetic theory, 7-9 geometrical arrangement of atoms in, for tungsten, 17, 18, 87 relation to potential energy of gas atom and solid, 6 determines potential field for rough surface, 6f.n. adsorbed atom, 20 theory of measurement, 7-9 number of atoms in, for tungsten, variation with heat treatment of 16, 17 wire, 12, 59-60, 85 Detailed balance, principle of, Adsorption, heat of, see Heat isotherm of, see Isotherm atomic hydrogen, production of, processes concerned, 66-7, 70-4 Ammonia, adsorption on barium fluoride, 123-4 deduction of Langmuir adsorption heat of adsorption of, 118 isotherm, 21 molecular constants of, 115 Dipoles, adsorbed on solid, statistical analyadsorption on caesium iodide, 122 sis for, 109-14 Atomic hydrogen, see Hydrogen electrostatic forces between, 107-9 heat of adsorption, see Heat Bare surfaces, induced by ionic crystal, 104 importance of, 3, 10, 12, 13 lattice of, interaction energy, 107 mutual depolarizing action of 105, effect of, on heat of adsorption, adsorbed on tungsten, effect on electron emission, 77 114, 118-19 each atom held on metallic surface, equivalent to electric dipole, 105 Emission of electrons, see Thermielectric moment per atom adsorbed onic emission on metal, 105 Energy, interaction, stability of adsorbed film of, on continuous variation over surface, tungsten, effect of oxygen, 77 for adsorbed particle, 36, 38-40 Carbon dioxide, fixed, statistical theory for, 24-33, 38 for immobile film, 32-3 heat of adsorption of, on barium fluoride, 124 for mobile film, 28 MAG

> INDEX 130 Energy, interaction (cont.) Film, adsorbed (cont.) see also Immobile film, Mobile film, Monomolecular layer of hydrogen on tungsten, only shortrange forces important, 29-30 of lattice of dipoles, 107 of linear chain, 43 Heat of adsorption, Energy, interchange, allowing for continuous variation of energy terms, 44-8 between helium and tungsten, 4 experimental results, application between solid and gas, 1, 3 between solid and gas, depends on to, 48-51 law of force, 5 deduced from rate of evaporation, between solid and gas, depends on 77, 91 masses, 2, 5 different from apparent heat of evaporation, 81, 89, 91 value of accommodation coefficient, effect of dipole forces on, 104, 110relation to, 2 Energy, potential, 24 between gas atom and solid surface, experimental procedure, 14-16 represented by Morse function, for simple adsorption, into mobile film, 27-8 indication of repulsive forces becontinuous variation over surface, tween adsorbed particles, 19 38-40 determined by structure of surface, measurement of, experimental arrangement, 13-14 of hydrogen on tungsten, 18, 19 electrostatic, 107-9 of mobile and immobile films, on Energy, states of minimum, localized sites, difference bedifference between mobile and immobile films, 22-3 tween, 21-3, 35, 37 reduction of, due to electrostatic effect of thermal motion, 23, 54 for linear chain, 49, 51-4 forces, 115, 120, 122 theory of, allowing for continuous for square array, 50 when occupation of a site precludes variation of potential energy, occupation of its neighbours, 44-8, 54 87 for constant dipole moment, 106, Evaporation, 111-12 for immobile film, 23, 32-3, 45-8, rate of, if interactions negligible, to determine apparent heat, 77-81 for mobile film, 22, 27-9, 44-7, when occupation of a site pre-87-9 use of wire as calorimeter, 13 cludes occupation of its neighwhen occupation of site precludes bours, 91 theory of, of adsorbed particles, 67occupation of its neighbours, 87-9 of atoms, 67, 71 Heat of evaporation, deduced from rate of evaporation, of molecules by combination of adsorbed atoms, 67, 72 77, 91 different from true heat of adsorpof molecules from atomic film, tion, 81, 89, 91 67, 73 Helium, accommodation coefficient of, 4 Film, adsorbed, temperature variation of, 4-5 accommodation coefficient, effect of, interchange of energy with solid, on, 4, 6, 12, 94-9, 102-3 forces between molecules, relation adsorption effects absent except at low temperatures, 4 to variation of heat of adsorp-

Hydrogen,

accommodation coefficient, on tung-

sten, measured, 12, 85

structure of, on known substrate,

tion, 19

3, 59, 95-8



INDEX

Hydrogen (cont.) accommodation coefficients, variation with heat treatment of surface, 12, 85 adsorption of, rapid on tungsten, 11, 12 exothermic process, 75

raises temperature of filament, 15 amount adsorbed, on surface planes of tungsten, 16-18

film adsorbed on tungsten, only nearest neighbours contribute to interaction energy, 29-30

heat of adsorption, measured variation, 18-19, 75

interpretation, 34-5, 48-51 molecular adsorption, 86

monolayer on tungsten, immobile, 35, 51, 55

ortho-para conversion of, on tungsten, 86

Hydrogen, atomic,

produced by hot tungsten filament, 65

rate of production, 65 effect of pressure on, 66 effect of temperature on, 66, 75 theory and experiment compared, 76, 85

theory of, 67, 70-5 trapped by film of molybdenum oxide, 65

Immobile film,

contrasted with mobile film, 21 f.n., 22-3, 35, 37, 59, 92-4

definition of, 22

equivalent to random distribution of occupied sites, 30

gaps in final film, 18, 33-4, 55, 92-4 as centres of catalytic activity, 55 f.n.

determined empirically, 56, 92 determined statistically, 55-6, 92 heat of adsorption, compared with experiment, 35

contrasted with that of mobile film, 23, 47, 89

for adsorption with dissociation, 30, 33-4, 93

for continuous variation of energy terms, 45-8

for simple adsorption, 23, 30 occupation of site precludes occupation of its neighbours, 91, 93 Immobile film (cont.)

rate of formation, occupation of site precludes occupation of its neighbours, 90, 93

of film formed by dissociation, 57, 59 93

131

statistical treatment, 30-3, 55-6, 92, 101

Indicator of adsorbed films,

measured accommodation coefficient as, 7, 60, 95-9, 102-3

Interaction energy, see Energy Isotherm, of adsorption,

for simple adsorption into mobile film, 27

from kinetic considerations, 74 long-distance order, effect on, 84 neglecting interactions, Langmuir, 21, 82

occupation of a site precludes occupation of its neighbours, 98 statistical derivation, 27, 82, 98

Kinetics of formation of monolayer, immobile film, formed with dissociation, 56-7

mobile film, formed with dissociation, 61-4

when occupation of site precludes occupation of its neighbours, 89-91

of adsorption of hydrogen, 57-9 of adsorption of oxygen, 100-3 Kinetics, chemical,

condition of quasi-chemical equilibrium, 35

use of, to examine nature of approximation of local configurations,

Kinetic theory,

and accommodation coefficient, 7-9 collision of gas atom and solid surface, 2

exact calculations, conditions under which possible, 1, 9

superseded by quantum theory of collisions, 3

Local configurations,

method of, introduced in theory of alloys, 25

used to determine equilibrium distribution, 24-5, 31, 109-11 used to determine heat of adsorption, 28, 32, 111-14, 116-19

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132

INDEX

Long-range forces,
effect of, on equilibrium properties
of monolayeı, 104
statistical analysis of, 124
see also Dipoles

Mobile film,
approximation of local configura-

tions, use of, 25 contrasted with immobile film, 21 f.n., 22-3, 35-7, 59, 92-4 definition of, 21 equilibrium distribution of particles

in, 24-7 heat of adsorption, for simple adsorption, 22, 27-8

for adsorption with dissociation, 28-30, 92

for continuous variation of energy terms, 44-7

when occupation of site precludes occupation of its neighbours, 92 interpretation of experimental heats of adsorption, 35, 48-51, 78-81 Monomolecular layer,

adsorption isotherm, Langmuir, 21 of oxygen, 98

statistical deduction of, 82

changes in, effect of, on accommodation coefficient, 12, 60-1, 94, 95-7, 99

contact potential, effect on, 57-9 different types, on array of localized sites, 21-3, 35, 37

effect on surface reactions, 1 evaporation and condensation processes, 21, 57, 62-3, 66-7, 70-4

formation, kinetics of, 55-7, 61-4 formation, rate of, 21, 57, 63 formed at very low pressure, 11, 13, 96

formed on clean surface, 1, 12-13 interchange of energy with gas atoms, effect on, 1

measured accommodation coefficient, effect on, 2, 4, 6, 11, 12, 60-1, 94, 95-7, 99

molecular or atomic film, depends on temperature, 86

occupation of site precludes occupation of its neighbours, 86, 89-92

of hydrogen on tungsten, 11, 16–19, 35, 58

Monomolecular layer (cont.)
of oxygen on tungsten, 59-61, 94-9
see also Heat of adsorption, Immobile film, Mobile film

Morse function, constants of, physical significance, 6 determination from temperature variation of accommodation coefficient, 6

definition, 6-7 potential energy of gas atom and solid, represented by, 6, 68

Neon,

accommodation coefficient, measured, 6, 12, 95, 96 f.n. effect of adsorbed impurities on,

6-7, 12, 60, 95-7 as indicator of adsorbed films, 7, 60,

96-7 Nitrous oxide,

heat of adsorption, on barium fluoride, 124

Oxygen,

effect of trace of, on accommodation coefficient of neon, 60, 94, 96 isotherm, of adsorption, 98 molecular adsorption, 86 monolayer of, on tungsten, rate of formation, 59 gaps in final film, 59, 96 heat of adsorption, 59–60 partial pressure of, relation to accommodation coefficient of neon, 96 structure of adsorbed film, 95–8

Partition function,
immobile film, 31
mobile film, 25-7
systems with long-range forces,
109-11
when occupation of site precludes
occupation of its neighbours,
92, 98
see also Vibrational partition func-

Potential energy, see Energy

Roughness factor, 6

tion

Solutions, theory of, contrasted with that of adsorbed monolayers, 35-7



INDEX 133

Solutions, theory of (cont.)
random mixture an approximation
to mixture with non-zero heat
of mixing, 35-6
Sulphur dioxide,
adsorption, on charcoal, 122
on barium fluoride, 123
heat of adsorption of, 123, 124
Surface,
bare, importance of, 3, 10, 12, 13
rapid adsorption of hydrogen on,
12
behaviour simplest in helium atmosphere, 4

cleaned by flashing, 14, 17
impurities, effect of, 2, 4, 12
necessary to keep free of, 3
interchange of energy with gas
atoms, 1, 3
see Immobile film, Mobile film,
Monomolecular layer

Thermionic emission,
effect of adsorbed caesium on, from
tungsten, 77
used to measure amount of adsorbed
oxygen, 77

Tungsten, adsorption on, of helium, 4 of neon, 6 contact potential of, with adsorbed hydrogen film, 58 adsorbed dipoles formed, with caesium, 105 removal of impurities from, 11, 14, surface plane, in aged tungsten, 16 thermionic emission from, effect of adsorbed caesium, 77 use of, as calorimeter, 13 Tungsten powder, interpretation of experimental heats of adsorption, 36 surface contaminated by impurities, 12 use of, unsatisfactory, in adsorption measurements, 12

Vibrational partition function,
effect on variation of heat of
adsorption, 51 f.n.
independent of state of occupation
of neighbouring sites, 24,
51 f.n.